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SUPERCONDUCTIVITY, SOFT MODES, AND PHASE TRANSITIONS

IN COMPRESSED Si TO 45 GPa

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ABSTRACT

A diamond anvil cell is used to measure the pressure dependence of the superconducting transition temperatures T in both primitive hexagonal and hexagonal close-packed (HCP) Si up to 45 GPa. The experimental results verify the prediction of superconductivity in HCP Si and the measured T versus pressure curve is found to be in good qualitative agreement with theory. A study of the role of soft phonon modes in enhancing T near structural phase transitions is presented along with calculations of the electron-phonon interactions.

Recently there has been considerable interest in the superconducting properties of Si under pressure. Chang et al. (hereafter referred to as I) reported a first principle calculation of the electron-phonon interaction parameter λ in primitive hexagonal (PH) Si and predicted that PH Si is superconducting with a transition temperature T in the range of 5-10 K. In I the theoretical prediction of superconductivity and the decrease in T with pressure P for P<30 GPa were verified experimentally up to 25 GPa using a Bridgeman-type opposed-anvil device. Subsequent calculation of λ in Si at higher pressures predicted that T in PH Si will reach a minimum around 30 GPa, then rise sharply to over 10 K between 35 - 41 GPa and finally transform into a superconducting hexagonal close-packed (HCP) phase around 41 GPa. The reason proposed for this unusual dependence of T on P was that before the PH to HCP transition the transverse acoustic (TA) phonon in the [001] direction of the Brillouin zone became soft and made a large contribution to the electron-phonon interaction.

After the theoretical predictions several groups tried to extend the T measurements in Si to higher pressures. Lin et 3 c al. recently reported T in Si <u>powder</u> at pressures up to 43 GPa c using a sintered-diamond-compact anvil device. Contrary to the theoretical predictions these authors observed no minimum in T as a function of pressure. However their results also differ significantly from those of I at pressures below 25 GPa; for example their value of (dT /dP) is smaller by one order of c magnitude. To resolve these differences between theory and experiment and between experiments, we have developed a new

technique for introducing copper wires into a diamond anvil cell (DAC) so that we can make low temperature four-probe electrical measurements at pressures exceeding 40 GPa. Using this technique we have measured the pressure dependence of T in single crystalline Si for the first time at pressures up to 45 GPa. We find good qualitative agreement with theory in that T reaches a minimum around 37 GPa and then increases sharply to 4.9 K before the PH to HCP transition around 40 GPa. This supports the suggestion that, before the structural phase transition, a soft phonon mode with a strong coupling to the electrons causes the increase in T . Furthermore we verify the predictions that HCP Si is superconducting and that T has a very small pressure coefficient in this phase. The measured value of T is 3.5 K for However the value of T before the PH to HCP transition HCP Si. above 10 K as predicted by theory. This discrepancy is not theory and experiment has been resolved by a between more complete calculation of the pressure-dependent electron-phonon in PH Si. interaction

Our experiments were performed with a DAC designed for use 4 at cryogenic temperatures. The cell is pressurized at room temperature with a hydraulic press and the pressure locked in with a retainer ring. This DAC allows pressures > 40 GPa to be achieved in a volume small enough to be inserted into an optical dewar, and the discovery of superconductivity in HCP Si presented here demonstrates the usefulness of DAC's in transport measurements at low temperatures and high pressures. The cell is used in a gasketed configuration with the single crystalline Si 14 -3sample (doped with 3x10 cm of phosphorus and approximately

25x25x75 um in size) placed in a 250 µm hole drilled in the steel gasket. Fine copper wires electrically insulated from the gasket by compressed Al O powder are pressed into contact with the Si sample. The arrangement of the wires relative to the sample is shown schematically in the upper inset of Fig. 1. A soft powder (Plaster of Paris) surrounds the sample to provide a quasi-hydrostatic environment. Small chips of ruby are placed adjacent to the sample for pressure measurement. It is assumed that the pressure coefficient of the ruby R - fluorescence is 3.65 A/GPa both at low temperatures and at room temperature. The sample temperature is monitored by a calibrated Si diode in thermal contact with one of the diamond anvils. The sample resistance is determined by measuring the ac voltage across the sample when excited by an ac current of 0.5 mA. The superconducting transition is always recorded both for increasing and decreasing temperatures. The rate of cooling or heating is kept low enough such that the cooling and warming curves show no hysteresis.

Figure 1 shows several resistance versus temperature curves of Si for pressures above 30 GPa. Because of pressure gradients across the sample, the drop in resistance (R) to the superconducting state always occurs over a small range of temperature. The width of this drop depends on pressure and this variation is related to changes in dT/dP with pressure rather than to changes in the pressure inhomogeneity.

To extract $T_{C}(P)$ from the experimental R versus T curves in a consistent and systematic way, we have developed the following

method. First we utilize the fact that, from I, T varies almost linearly with P between 20 to 25 GPa. This knowledge enables us to deduce from the R versus T curves at low pressures a pressure distribution function $\Delta P(x)$, where x represents the fractional length of the sample with a given pressure deviation ΔP from the mean pressure. This is shown in the lower inset of Fig. 1. Typically we find that about $40 \ \%$ of the sample is isobaric. This pressure distribution is assumed to remain unchanged with The T (P) curve above 25 GPa is then obtained by pressure. fitting the experimental R versus T curves. For each curve the mean pressure is determined from the fluorescence of ruby chips around the sample measured while at cryogenic temperature. (This happens to be nearly equal to the pressure of the ruby chip closest to the center of the sample.) The T (P) curve obtained in this way is shown in Fig. 2 as the solid circles.

In Fig. 1 some of the computed R versus T curves based this T vs P curve and the $\Delta P(x)$ distribution shown in the inset are compared with the measured curves in Fig. 1. The agreement between the computed curves and the measured curves is fairly good and supports the validity of this procedure. The error bars in Fig. 2 represents the spread in pressure inside the cell as determined from ruby chips around the sample. The fact that this spread remains more or less independent of pressure is consistent our assumption that the pressure distribution over with the sample remains unchanged as the pressure is increased. 0 n releasing the pressure we found good reproducibility in the Ρ dependence of T as long as P is above 15 GPa.

Our results for the pressure dependence of T for P less than 30 GPa are in good agreement with the results of I and in disagreement with the result of Lin et al. The difference in pressure of about 3 GPa between our results (shown as the solid curve) and those of I (shown as the dotted curve) in Fig.2 can be attributed to the different methods in determining the pressure. In the P > 30 GPa region we found that T reached a well-defined minimum of 3.3 K at 37 GPa in good agreement with earlier theoretical work. However, while this theory predicted that T would increase sharply between 35 and 41 GPa, the measured T increased to only 4.9 K.

It was recognized in the earlier calculation of $\lambda(P)$ that the use of just the [001] direction for obtaining the average λ is a shortcoming of the calculation. This appears to be the origin of the difference between theory and experiment. In this paper we report new calculations for λ in other high symmetry directions. As shown in Fig. 2, the electron-phonon interaction for ql[[011] behaves differently compared to ql[[001]. A large enhancement of λ for ql[011] in the region of low pressure results from the soft TA mode in the PH phase. This phonon mode is 8.9 associated with the PH to β -Sn phase transition and its frequency goes to zero at the corresponding transition. So the spherical approximation based on λ for phonons with qH [001] underestimates the value of λ at P below 35 GPa and overestimates it above 35 GPa. In contrast, the electron-phonon interaction for $q \parallel [010]$ varies little and has a minimum at P around 33 GPa. The weighted average of these three different contributions to λ reaches a minimum at 33 GPa in agreement with experiment to

within 10 % except for the region close to the β -Sn to the PH phase transition. Close to this phase transition we find that, as in the case of the PH to HCP transition, the electron-phonon interaction is strongly influenced by the soft mode. This point be elaborated further below. Here we point out that will the "measured" electron-phonon coupling constants are derived from using the McMillan equation the measured with Т the longitudinal acoustic phonon frequency for $q\parallel[001]$ as a cutoff in the phonon spectrum and assuming a Coulomb interaction of 0.08. The calculated T's are compared with the measured values in Fig.2 and the agreement is reasonably good.

The role of soft phonon modes in enhancing T can be explained by examining the volume (V) dependence of λ . From the expression for λ , the volume dependence of λ can be expressed as:

$$\frac{d(\ln\lambda)}{d(\ln V)} = \frac{d(\ln N(E_f))}{d(\ln V)} + \frac{d(\ln \ll M^2 >>)}{d(\ln V)} - 2\frac{d(\ln\omega)}{d(\ln V)}$$
(1)

where N(E) is the electronic density of states at the Fermi 2 energy. The square of the electron-phonon matrix element <<M >> is averaged over the Fermi surface and ω is the phonon frequency. For P < 30 GPa in PH Si we estimated that the terms on the right hand side of Eq. 1 are approximately 0.34, -2 and 5 respectively. This shows that the volume dependence of λ is dominated by the volume dependence of the phonon frequency. Thus in general one may expect λ to be enhanced when the phonon becomes soft. We find that this is responsible for the high T in PH Si near the structural transitions into both the β -Sn and the HCP phases. Although in case of the PH to the HCP transition.

we find that the matrix element term in Eq. 1 also makes a significant contribution to the enhancement of T .

Above 40 GPa the measured T drops quickly down c to 3.5 K, and for even higher pressures T increases only c slightly. This drop occurs exactly at the pressure where the x-ray 13 diffraction measurement of Olijnyk et al. have found the transition to the HCP phase occurs. Hence we have attributed the sudden drop in T at 40 GPa to a transition to a superconducting HCP phase and in this phase T has a very small positive pressure coefficient of dT /dP = 0.03 K/GPa.

An additional phase transition into a new and unidentified intermediate phase has been observed by Olijnyk et al. in Si between 36 and 40 GPa and has been labelled by these authors as Si VI. However, this claim has been disputed by Spain and If we assume that a transition exists, the x-raycoworker. diffraction pattern attributed to Si VI can be explained quite 15 satisfactorily by a double hexagonal (DH) crystal structure. Α total energy calculation performed for DH Si shows that the DH phase is metastable with respect to the HCP phase with an energy difference of 0.03 eV. If further x-ray diffraction studies confirm the existence of an intermediate phase, Si VI, then our experimental results indicate that this intermediate phase is also superconducting and that T has a large positive coefficient in this phase.

In conclusion we have developed a DAC capable of performing electrical measurements at cryogenic temperatures up to 45 GPa and we have used this cell to measure the pressure dependence of T in Si. We find good agreement between experiment and present c

a more complete theoretical calculation of the electron-phonon coupling constant in PH Si. We demonstrate that by studying the pressure dependence of T it is possible to explore the role of enhancing superconducting transition modes soft phonon in Since compressed Si behaves like a typical BCS temperatures. superconductor, we expect the relationship between soft phonon modes. structural phase transitions and superconductivity discussed here to be applicable to other systems.

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FIGURE CAPTIONS

Comparison between the experimental and computed R Fia. 1 versus temperature curves for Si at several pressures. The computed curves are based on the the pressure distribution shown in the lower inset, where X is the fractional length along the sample, and the T_c vs P curve shown in Fig. 2. The upper inset shows a schematic arrangement of the copper wires (W)relative to the Si sample (S). G is the steel gasket. Pressure dependence of (a) T , (b) averaged λ and Fig. 2 (c) contributions to λ from phonons propagating along three directions. In (a), the solid circles represent experimental points and the open circles theoretical In (a), (b) and (c) the curves have been drawn points. as a guide to the eyes with the broken lines representing the theoretical values and the solid curves experimental values. The dotted curve is the result of I.



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